

Flux Pinning Characteristics of Y-Ba-Cu-O Thin Films with Vertically Aligned ZnO Nanorods

S. K. Oh^{a, *}, G. E. Jang^a, O. B. Hyun^b

^a*Department of Advanced Materials Engineering, Chungbuk National University, Cheongju, 361-763, Korea*

^b*Korea Electric Power Research Institute, Daejeon, 305-380, Korea*

For wide applications of high-temperature superconducting materials, large critical current density (J_c) in high applied magnetic fields are required. A number of methods have been reported to introduce artificial pinning centers (APCs) in $\text{YBa}_2\text{Cu}_3\text{O}_{7-\delta}$ (YBCO) films for enhancement of their J_c . We studied the superconducting properties of YBCO thin films with vertically aligned ZnO nanorods. ZnO nanorods were grown on sapphire substrates by thermal CVD method. YBCO films and CeO_2 were deposited by on-axis RF sputtering on sapphire substrates with grown nanorods. Improvement in in-field J_c was achieved by incorporation of vertically aligned ZnO nanorods within YBCO films. Microstructural analysis of the obtained YBCO films was performed by using cross-section transmission electron microscopy (TEM). Phase and textural analysis was done using X-ray diffraction. According to the cross-sectional TEM images, the columnar defects comprised of vertically aligned ZnO nanorods along c-axis are clearly observed in the films.

Key words: YBCO, flux pinning, nanorods